APR 1 8 2005 BY IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
Song et al.) Group Art Unit: 1752
Serial No.:10/720,966) Examiner: John S. Y. Chu
Filed: November 24, 2003) Confirmation No.: 5221
For: PHOTORESIST COMPOSITION AND METHOD PATTERN FORMING USING THE SAME) TKHR Docket: 250913-1030) Top-Team: 0424-8857US

Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Mail Stop Amendment; Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450, on April 14, 2005.

Signature – Hui Chin Barnhill

RESPONSE TO RESTRICTION REQUIREMENTS

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed March 24, 2005 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.